

Ge

GERMANIUM SPUTTERING TARGET

Germanium is a chemical element with the symbol Ge and atomic number 32. germanium is a semiconductor and frequently utilized in the fabrication of transistors and integrated circuits. It is often evaporated under vacuum to create layers in the production of optical storage media and optical coatings. Other uses of the material are as an alloying agent and catalyst.

Quick Facts

Product	:	Germanium Sputtering Target
Stock No	:	NS6130-10-1135
CAS	:	7440-56-4
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1135	99.99%	50.8 mm \pm 1mm	3 mm \pm 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
Ge	72.63g/mol	938.25°C



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High Purity
SPUTTERING
TARGET